



IPW

IN THE U.S. PATENT AND TRADEMARK OFFICE

Appl. No. : 10/727,901
Applicant : Rosenbluth, Alan E.
Filed : December 4, 2003
TC/AU : 2851
Examiner : Gutierrez, Kevin C.

Docket No. : YOR920030339US1
Customer No. : 29683

Title : PRINTING A MASK WITH MAXIMUM POSSIBLE PROCESS WINDOW
THROUGH ADJUSTMENT OF THE SOURCE DISTRIBUTION

Mail Stop Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT

Sir:

In response to the Office Action dated July 22nd, 2005, please amend the above-identified application as follows.

Amendments to the Specification begins at page 2 of this paper.

Amendments to the Claims begins at page 3 of this paper.

Amendments to the Drawings: None.

Remarks/Arguments begins at page 5 of this paper.

Appendix: None.

Applicant believes that the filing of this paper is within the allotted shortened statutory period for reply. However, should the undersigned attorney be mistaken, please consider this a petition for an extension of time that may be required to maintain the pendency of this patent application, and charge Deposit Account No. 50-0510 for any required fee deficiency.